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Been-Yih Jin et al.

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Other Documents (include Author, Title, Date, and Place of Publication)							
Examiner Initial	Desig. ID	Document					
RP	AF	Chau et al., International Electron Devices Meeting 2000, San Francisco, CA, December 10-13, 2000.					
RP	AG	Ghani et al., Symposium on VLSI Technology Digest of Technical Papers, Honolulu, HI, June 13-15, 2000.					
RP	АН	Hubbard et al., "Thermodynamic stability of binary oxides in contact with silicon" J. Mater. Res., Vol. 11, No. 11, Nov. 1996.					

Examiner Signature	Ron	Pompey	٠.	Date Considered	2-05-05
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EXAMINER: Initials citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.